

APS Optics Metrology

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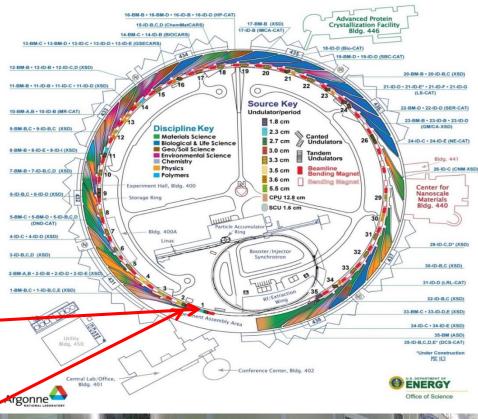


Outline

- Introduction
- Optical Metrology
- At-Wavelength Metrology
- Summary



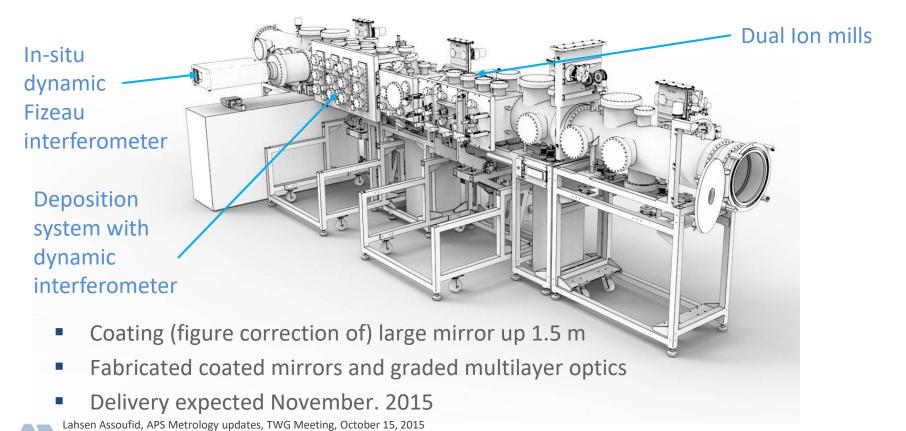






New Modular Deposition System with integrated Insitu Ion Beam Milling and Metrology

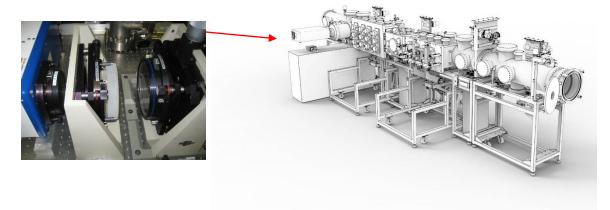
- Effective use of low-emittance will require optics with dramatically smaller figure errors and tailored surface profiles/
- APS in investing in a new deposition system that allow advanced thin film optics including.



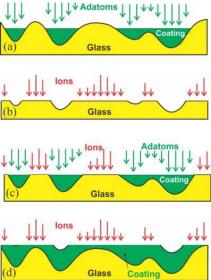
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New Modular Deposition System with integrated Insitu Ion Beam Milling and Metrology

- The system includes a Fizeau interferometer for measurement of mirrors profile.
- Maintains the mirror under vacuum through the fabrication process
- Fast iteration rate for recoating/milling
- Ability to avoid oxidation (metals, etc.)



- Extremely accurate registration between Fizeau and ion mills/coatings for accurate fabrication of optics
- Coating (figure correction of) large mirror up 1.5 m
- Fabricated coated mirrors and graded multilayer optics



Surface correction techniques: (a) differential deposition, (b) ion-beam figuring, (c) combination, (d) ionbeam figuring of overcoating

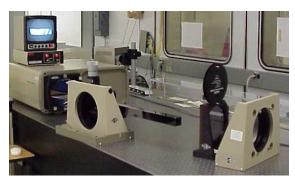
(R. Conley)

Optical Metrology

- Current capabilities:
 - New slope measuring system in the NOM configuration with <50 nrad precision on flat mirrors
 - Roughness and stitching microscope interferometer (MicroXAM RTS), <
 0.05 nm height resolution
 - Laser Fizeau Interferometer (Wyko 6000), 150 mm aperture, <1 nm resolution.



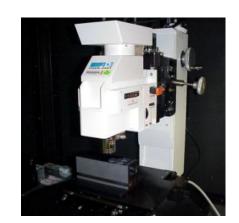
The APS slope measuring profiler (2011-12)



Wyko 6000 Interferometer (1994)



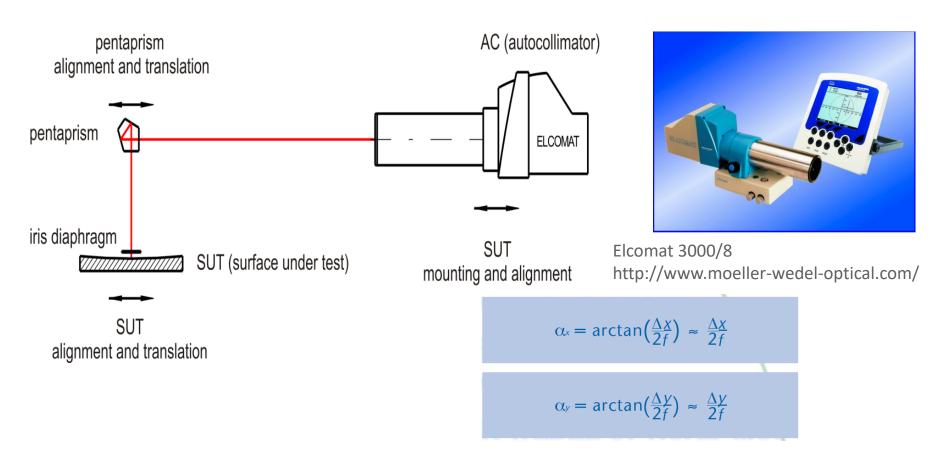
4-D Technology's FizCam for in-situ metrology (2015)



MicroXam RTS roughness/microstitching microscope (2006)

Lahsen Assoufid, APS Metrology updates, TWG Meeting, October 15, 2015

Autocollimator and a moving mirror pentaprism based slope profiler (NOM concept)



^{*}F. Siewert, H. Lammert, T. Zeschke, Modern Developments in X-ray and Neutron Optics, Springer 2008

DOE Metrology & Accreditation Committee 2013 Annual Conference, ORNL, May 12-13, 2013



The image of an illuminated object, located in the rear focal plane of the collimator lens, is projected to infinity and reflected via mirror. The image is picked up by a light-sensitive receiver.

A slight alteration of the angle between the optical axis of the autocollimator and the mirror causes a deviation which can be determined very precisely.

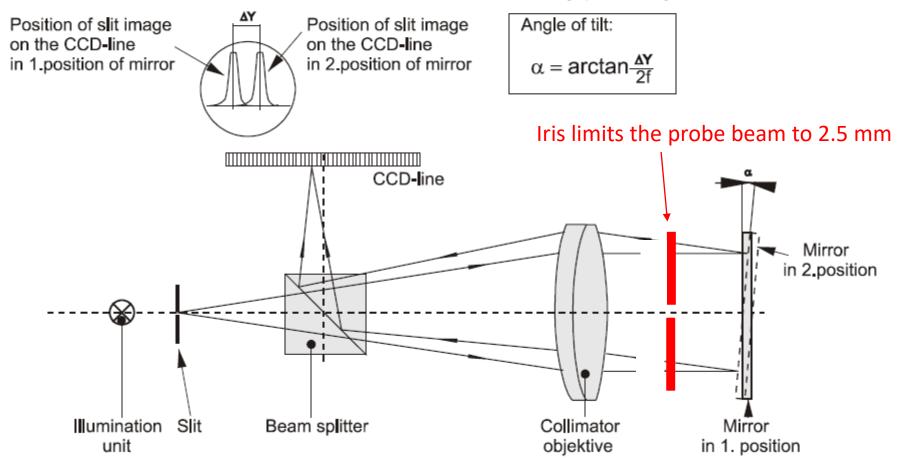


Fig.2: Measuring principle of autocollimation

7.1 Autocollimation Measuring Head

Objective lens: Free aperture 50 mm

Focal length 300 mm

Illuminated measuring aperture ca. 32 mm

Light sources: High power LED

Wave length 660 nm

Detectors: CCD elements

Adjustment and alignment aid: Laser attachmnet D65 (to be ordered sepa-

rately)

FOV: approx. 57 arcmin

Measuring range:

- total range ±17.5 arcmin (corresponds to ±1050")

- distance autocollimator/mirror: up to 2500 mm: ±1000"

up to 3000 mm (theoretical): ± 885"

up to 7000 mm (theoretical): ± 365"

Measuring rate: 25 Hz

Measuring accuracy:

for any 20" measuring range (in absolute measuring mode)
 ±0.10"

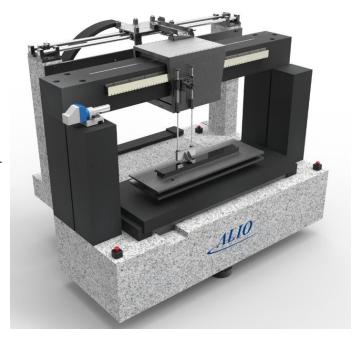
- for the entire measuring range ±0.25"

(The measuring range depends on the measuring distance, see above.)

Display-resolution: 0.005"

The APS slope measuring profiler design

- Gantry System:
 - Alio Industries (APS Design)
 - Scan length up 1.5 m
- Slope sensor
 - Autocollimator: Elcomat 3000/8, MÖLLER-WEDEL
 OPTICAL GmbH, model
 - Resolution ~ 50 nrad
- scanning opto-mechanics and mirror support table: APS
- Data acquisition: EPICS based, APS BCDA
- Data processing: Pyhton-based, APS



LTP 3-D drawing by O. Schmidt



Additional Mounting Location for Additional User Added Functionality.

Cable axis

Metrology axis

Cable Axis 100%
Isolated from the Optical
Carriage with Isolated
Granite and Frame.

Soft / Gentle Cable Loop from Cable Axis to Metrology Axis for Motor and Encoder Cables.

Metrology Risers
Separate / Isolated from
the Axis / Motion Risers

Positioning accuracy 50 nm. A factor of 2000 improvement over previous LTP

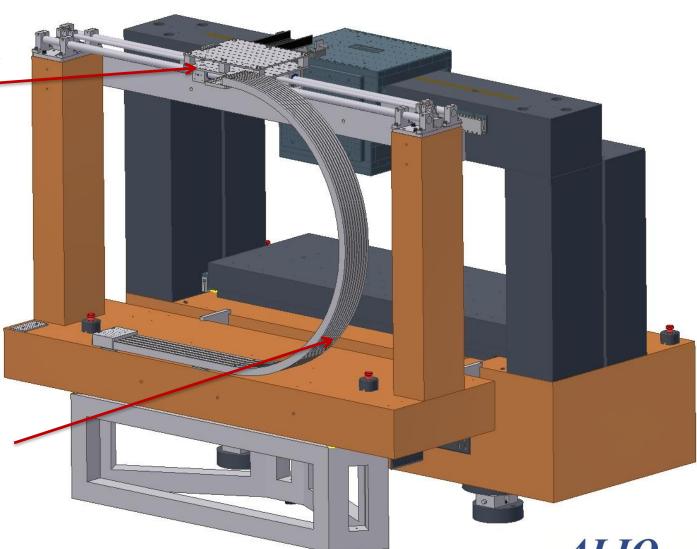
Mirror granite table

ALIO 6-D

Lahsen Assoufid, APS Metrology updates, TWG Meeting, October 15, 2015

The APS Slope Measuring Profiler: The Gantry System Design

Completely Separate Air Bearing Servo Axis for Cable Axis. Axis Mirrors Motion of Optical Carriage Thus Isolating Cable Drag and Vibration.



Large Radius Cable Loop to Minimize Vibration and Drag.

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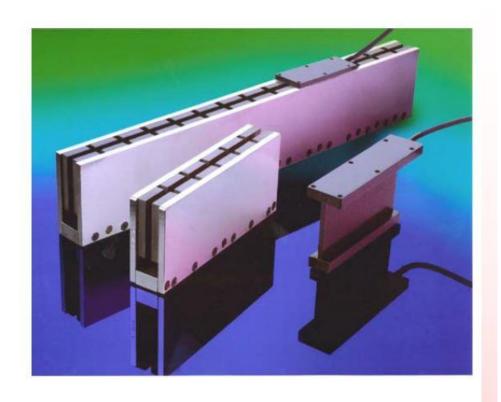
Motion system

Brushless Linear Servo Motors designed for Advanced Motion Applications

Designed for today's most advanced applications, Airex Brushless Linear Servo Motors offer the absolute best in linear motion technology.

Airex patented machine winding technology produces motors with exceptional performance, smooth motion, high accuracy, unmatched

P20 Motor Data



FEATURES:

http://www.airex.com/wp-content/Linear_Motr/P20%20Motor%20Data%20f.pdf

Lahsen Assoufid, APS Metrology updates, TWG Meeting, October 15, 2015

Motion system specs and test results

Table 1. Test results with specifications for the Long Trace Profiler system: X axis

TEST	TEST METHOD	TEST LOCATION	SPEC	ACTUAL
X AXIS				
TRANSLATION RANGE	CONTROLLER (1)	ANL	1500 mm	1520 mm
MINIMUM VELOCITY	CONTROLLER (1)	ANL	0.1 mm/sec	verified
MAXIMUM VELOCITY	CONTROLLER (1)	ANL	20 mm/sec	verified
ACCURACY (GLOBAL)	LASER (2)	ANL	+/- 3 um	+/- 0.277 um
ACCURACY (LOCAL)	LASER (3)	ANL	+/- 0.3 um / 100 mm	+/-0.172 um
REPEATABILITY (GLOBAL MOVE)	CAP GAUGE (4)	ANL	+/- 500 nm @ 1 σ	+/- 24 nm (1 σ)
PITCH (TILT) REPEATABILITY			+/- 100 nrad @ 1 σ	
(THETA Y OF X CARRIAGE)	CAP GAUGE (4,5)	ANL	+/-xx nm @ x00mm (1 σ)	+/- 33 nrad (1 σ)*
YAW (TILT) REPEATABILITY			+/- 100 nrad @ 1 σ	
(THETA Z OF X CARRIAGE)	CAP GAUGE (4,5)	ANL	+/-xx nm @ x00mm (1 σ)	+/- 54 nrad (1 σ)*
ROLL (TILT) REPEATABILITY			+/- 100 nrad @ 1 σ	
(THETA X OF X CARRIAGE)	CAP GAUGE (4,5)	ANL	+/-xx nm @ x00mm (1 σ)	+/- 79 nrad (1 σ)*
PITCH	LASER (2)	ANL	+/- 5 urad (+/- 1 arc-sec)	+/- 2.6 arc-sec
YAW	LASER (2)	ANL	+/- 5 urad (+/- 1 arc-sec)	+/- 0.5 arc-sec
ROLL (DUAL FLATNESS)	LASER (2)	ANL	+/- 5 urad (+/- 1 arc-sec)	+/- 1.25 arc-sec
FLATNESS	LASER (6)	ANL	N/A	+/- 3.7 um
STRAIGHTNESS	LASER (6)	ANL	N/A	+/- 1.7 um
CURRENT DRAW ON AMPLIFIER	CONTROLLER (1)	ANL	<1W	<< 1 W



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Delivery of the gantry system: August 2011





Assembling and Installation: Sept - Oct. 2011



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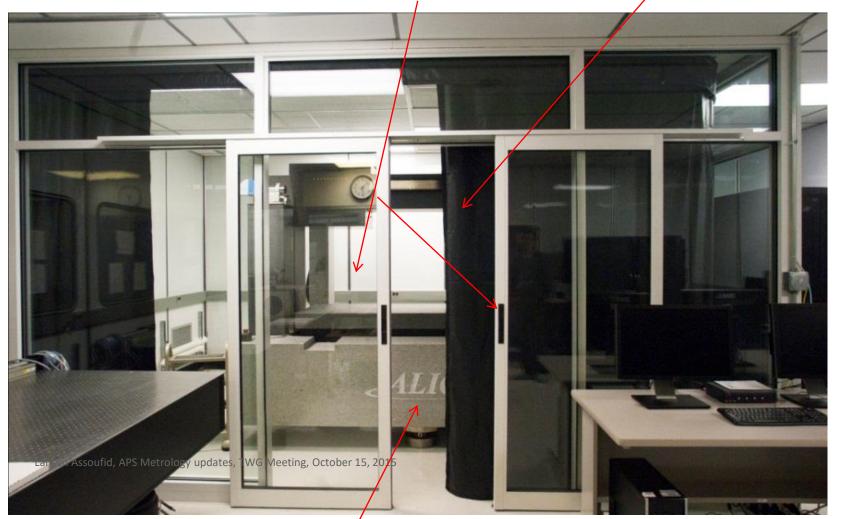
Construction of the Enclosure Nov. 2011



Enclosure construction: Dec. 2011

Laser curtain/visible light shield

Double sliding doors

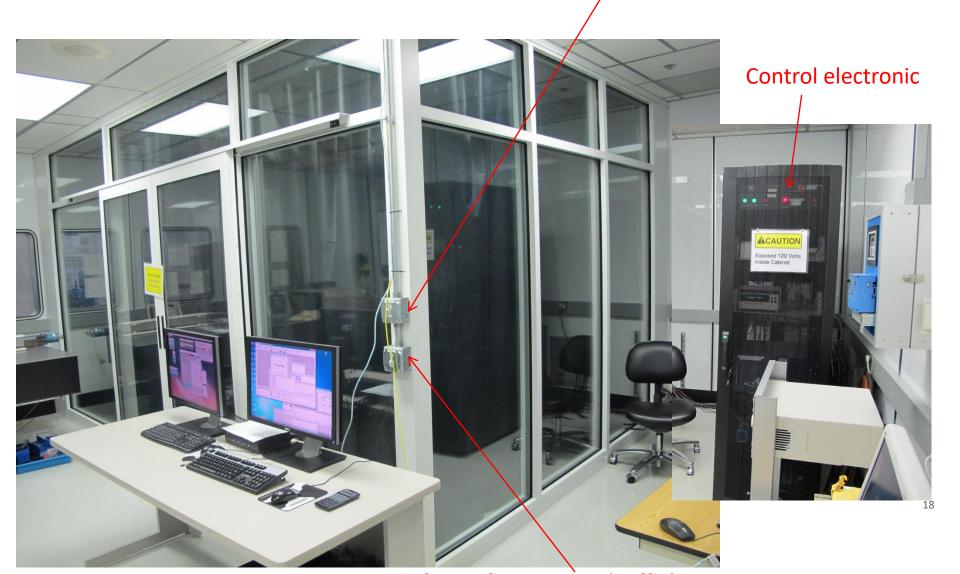


Granite table supported on an industrial kinematic mount

Has a separate air handling control

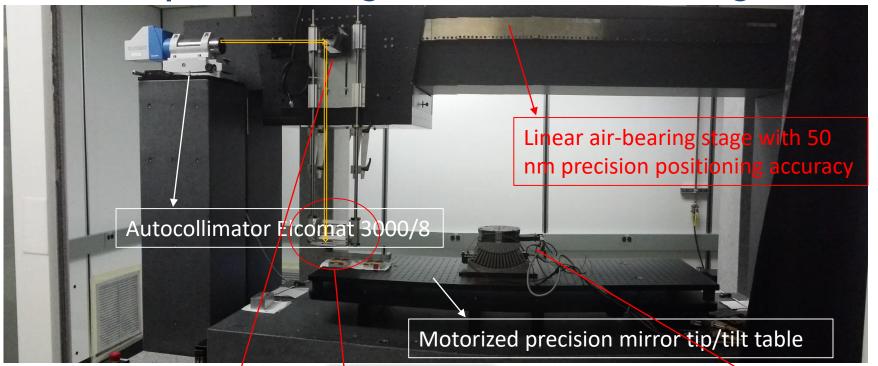
Commissioning Jan. 2012

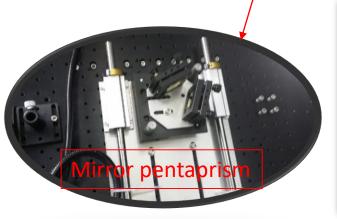
Light switch



Switch for air flow system (baffle)

APS Slope Measuring Profiler in NOM Configuration







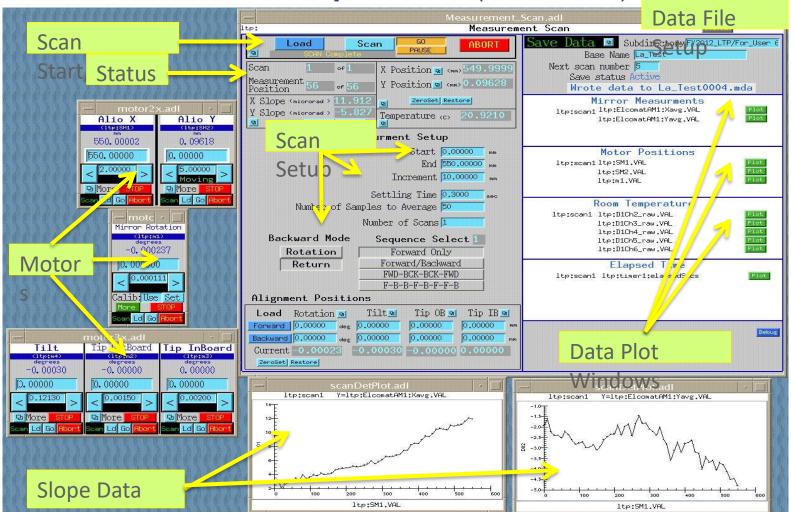
Mirror pentaprism for measurement of horizontal deflecting mirror

2.5 mm diam iris

Small angle generator for angle calibration and for curved mirror measurement by stitching

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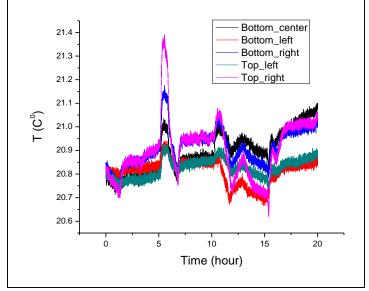
EPICS-based Data Acquisition (2011-12)

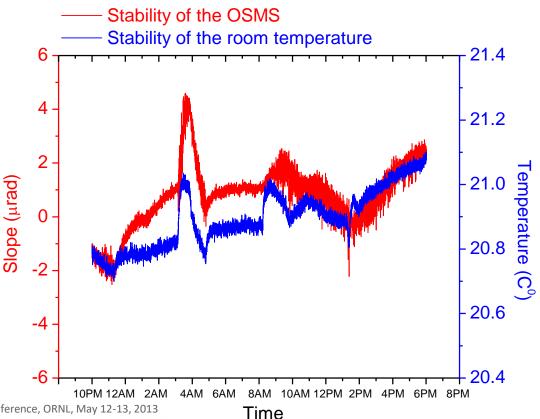


J. Sullivan, P. Jemian, L. Assoufid EPICS Based Data Acquisition (unpublished)



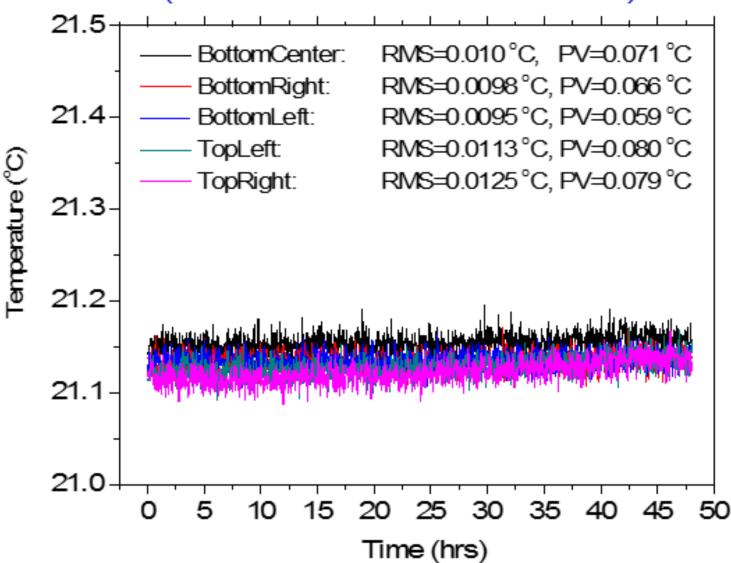
Stability of the APS OSMS vs. the stability of the room temperature in 20 hours





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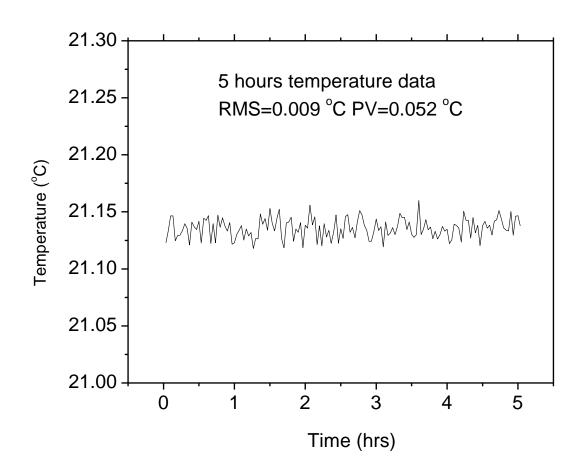
Temperature inside of the AC-LTP enclosure (48 hours from 5/23/2014 to 5/25/2014)





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Temperature stability: 2015





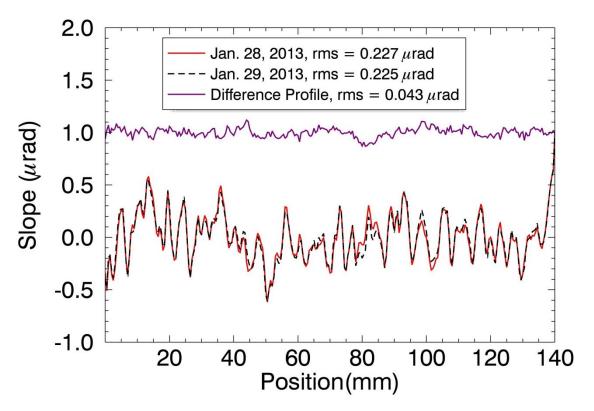
- Air handling system turned off
- Excellent temperature stability obtained within a few hours.
- Further improvement are expected to be achieved by adding another enclosure around the instrument.

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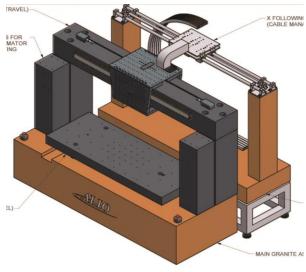
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New Slope Profiler: Repeatability and accuracy

- Test mirror: 140-mm Si, 0.2 μrad rms slope error
- Two different measurement taken at 1 day interval







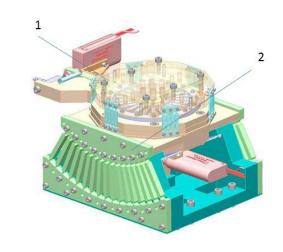


Recent In-house Developments and Implementations

- New Python-based data processing software: (OMEN)
- Calibration
 - Prototype of a small angle generation device for calibration was developed and tested:
 - Flexural stage (by D. Shu)
 - EPICS-based control and acquisition software (J. Sullivan)



- Automated tip/tilt stage and subaperture/segmented measurements
- EPICS-based control and data acquisition software.
- All developed in-house.



- Fine adjustment driven by a PZT with a maximum range ~0.6 mrad with 20 nrad resolution.
- Limitation: Coarse adjustment driven by a PicoMotor with a range of up to 9 mrad

Deming Shu, et al. SPIE Vol. 9206 (2014)

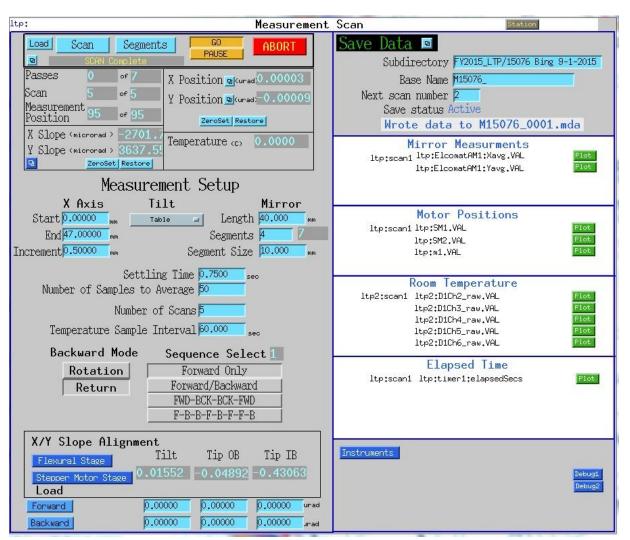
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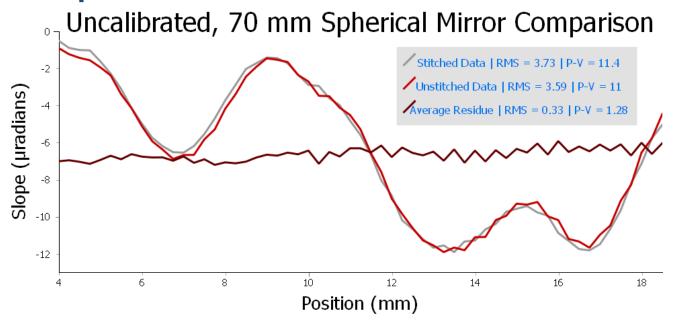
Automated tilting stage for subaperture scanning and stitching: EPICS user interface.

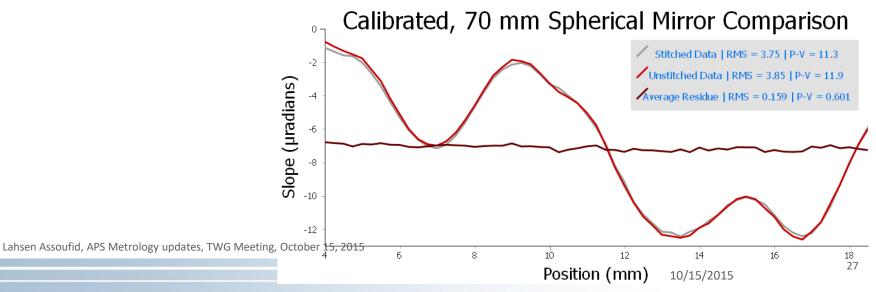
Completed August 2015

 In-house developed software for high precision mirror tilt and positioning for subaperture scanning and stitching.



Measurement of a Curved Mirror by Stitching: Comparison with Calibrated data





General issues about scanning deflectometric profilers

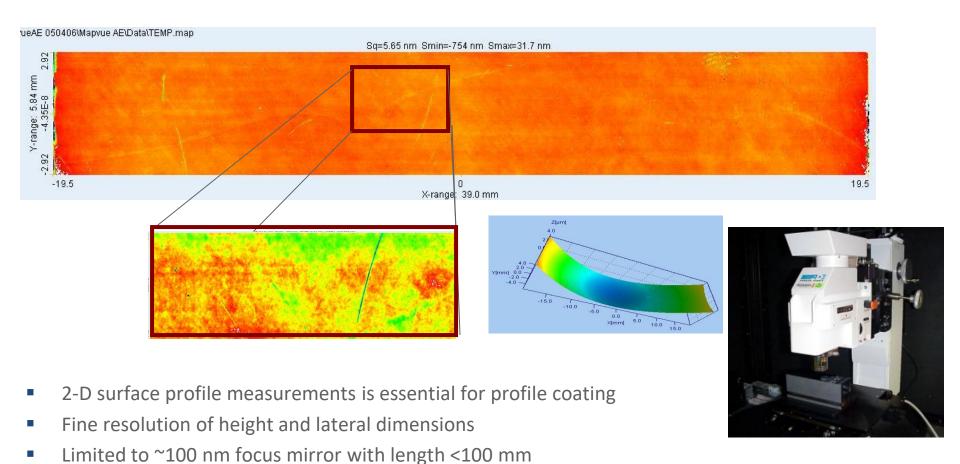
- Deflectometers (pencil beam LTP, NOM), are typically one dimensional profilers. Characterization of focusing optics generally requires two dimensional metrology tools. (Bender twist can not be easily "seen" with 1-D profilers)
- Scanning devices require long measurement time, which makes the measurement prone to drift error.
- Their variable optical path length make them prone to external perturbations
- Measurements can be affected by:
 - systematic/residual errors of scanning stage (in addition to aberrations of the internal optics)
 - Possible non linearity of the slope sensor
 - Environment effect: temperature stability, electronic and acoustic noise
- Very large (> a few km) and very small (<100m) radii of curvature are very challenging to measure

Autocollimator-based profilers limitations and needs

- Auto-collimator-based slope measuring profilers limitations:
 - Spatial sampling limited by the size of the probe beam (~2.5 mm).
 - Measurement of curved mirrors limited by the autocollimator dynamical range and (few 10 microrads) and non linearity for steep slopped surfaces.
 - Require precise calibration or and sub-aperture/segmented measurement stitching.
 - Highly sensitive to external temperature fluctuations.
- New sensors must be developed to overcome these limitations
- Collaborative efforts with other synchrotron labs, with active participation of industrial vendors of x-ray optics and metrology instrumentation is necessary to advance metrology capabilities.



Roughness and Micro-stitching Interferometer

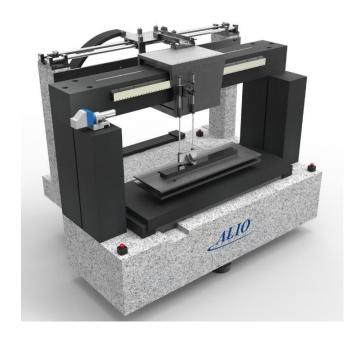


Achieving K-B mirrors with 50-nm focus requires an improved microstitching system to subnanometer figure error

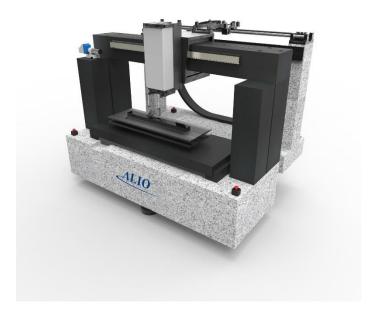
Photo of the APS MicroXam RTS roughness & microstitching interferometer



Future development: 2-D dimensional surface profile measurement of large mirrors



Current sensor: Autocollimator



Future sensor: 2-D stitching

Summary

- The 4th generation light sources require advanced optics:
 - Mirror with unprecedented quality with slope error in the nrad range
 - Wavefront preserving optics for imaging
- Developing a new generation metrology tools is thus essential for both quality control and to support in-house optics fabrication and development.
- New metrology upgrades to support APS beamlines and APS-U include:
 - A new slope measuring profiler with <50 nrad rms resolution on flat mirrors up 1.5 m long.
- Future development:
 - Develop sensor/procedures for measuring curved optics
 - Implement a 2-D sensor with stitching for mirror up 1.5 m



Acknowledgements

Slope measuring profiler:

Jun Qian - Metrology measurements

Josef Sullivan - Data acquisition and control software

Mark Erdmann and Scott Izzo - Mechanical Engineering and design work

Curt Preissner - Vibration measurements

Jeff Collins - Temperature survey

John Sidarous, Andy Stevens, Marvin Kirshenbaum - Enclosure and cleanroom upgrades

Deming Shu – small angle generator design

Ben Sheff (Berkeley University, Summer Intern): Data processing software

Pet Jemian and Brian Toby support with data acquisition and analysis software

At-wavelength metrology

Shashi Marathe - Grating interferometry development

Xianbo Shi - Coherence measurements and simulation

Al Macrander and Stan Stoupin - 1-BM experiments

Erika Benda - Portable Grating interferometer Mechanical design

Dan Nocker - Grating interferometer assembling

Keenan Land and Kurt Goetze - motion electronics and control

APS/XSD management for support

Work supported by the U.S. Department of Energy, Office of Science, under Contract # DE-AC02-06CH11357

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Thank you!